L Number	Hits	Search Text	DB	Time stamp
	329	396/611 118/052	USPAT	2004/06/24 11:34
1	1432	430/396	USPAT	2004/06/24 11:35
2		430/296	USPAT	2004/06/24 11:35
3	2081		USPAT	2004/06/24 11:35
4	2408	(396/611 118/052) 430/296	1	2004/06/24 11:33
5	. 2	5025280.pn. 6575645.pn.	USPAT	·
6	3750	((396/611 118/052) 430/296) 430/396	USPAT	2004/06/24 11:40
8	459	(((396/611 118/052) 430/296) 430/396) and	USPAT	2004/06/24 11:41
		(polish\$3 planariz\$5)		
9	462	((((396/611 118/052) 430/296) 430/396) and	USPAT	2004/06/24 11:41
		CMP) ((((396/611 118/052) 430/296)		·
		430/396) and (polish\$3 planariz\$5))		
10	1095	$(((396/611\ 118/052)\ 430/296)\ 430/396)$ and	USPAT	2004/06/24 11:41
	1033	(processor computer memory)		
11	3	$((((396/611\ 118/052)\ 430/296)\ 430/396)$ and	USPAT	2004/06/24 11:54
1 1 1]		001111	2001, 00, 21 22101
		(processor computer memory)) and		
l _		(spectrophotometry reflectometry)	HODAM	2004/06/24 12:21
7	83	(((396/611 118/052) 430/296) 430/396) and	USPAT	2004/06/24 13:21
		CMP		0001/05/01 11 55
12	1835	"UV/vis spectrophotometry" scatterometry	USPAT	2004/06/24 11:56
		ellipsometry "x-ray reflectometry"	•	
13	131	("UV/vis spectrophotometry" scatterometry	USPAT	2004/06/24 11:57
	İ	ellipsometry "x-ray reflectometry") and		
		(develop\$3 same resist)		
14	88	(("UV/vis spectrophotometry" scatterometry	USPAT	2004/06/24 13:09
		ellipsometry "x-ray reflectometry") and		-
		(develop\$3 same resist)) and ("process		
		controller" computer memory)		
15	50	trim adj etch\$3	USPAT	2004/06/24 13:09
		(trim adj etch\$3) and (lithography resist)	USPAT	2004/06/24 13:10
16	37	(trim adj etchips) and (frichography resist)	USPAT	2004/06/24 13:22
17	9126	(cmp polish\$3 planariz\$4) and develop\$3	USPAI	2004/00/24 13.22
		and resist		2004/06/04 13:22
18	459	(cmp polish\$3 planariz\$4) same (develop\$3	USPAT	2004/06/24 13:22
1	1	with resist)		0004/05/5: 55 55
19	163	(cmp polish\$3 planariz\$4) with .(develop\$3	USPAT	2004/06/24 13:22
		with resist)		
-	7.6	"5905020" "5840199" "5756256" "6221562"	USPAT	2004/06/24 11:33
		"6107172" "5294291" "4224361" "4119483"		
-	132	"5905020" "5840199" "5756256" "6221562"	USPAT	2003/09/30 13:57
		"6107172" "5294291" "4224361" "4119483"		
		"5033998"		
_	78	coat\$3 and resist and (pattern\$3	USPAT	2003/09/30 14:00
	, ,	develop\$3) and (elipsometry "uv/vis" "xray	1	
		reflectometry")	1	
	1		USPAT	2003/09/30 14:02
_	24	(coat\$3 and resist and (pattern\$3	OSEMI	2003/03/30 14.02
1		develop\$3) and (elipsometry "uv/vis" "xray	1	*
	*	reflectometry")) and (processor computer	1	1
		microprocessor)]
-	452	156/345.22 156/345.13 156/345.24	USPAT	2003/09/30 14:26
		156/345.12		
-	0	"trim etchant"	USPAT	2003/09/30 14:26
l = .	235	trim with etch\$3	USPAT	2003/09/30 14:27
-	1	6589869.pn.	USPAT	2003/10/01 14:53
_	1	6413867.pn.	USPAT	2003/10/01 14:53
L	1	1 0 1 1 0 0 0 1 1 PALL	1	